



# NaPa

## Emerging Nanopatterning Methods

The NaPa Integrated Project Consortium has the mission to develop a library of processes for nanopatterning based on novel methods like nanoimprint lithography, self assembly, soft lithography, stencilling, scanning probes and UV-nanoimprint lithography.

# www.NaPaIP.org



LUND UNIVERSITY



## csem

PAUL SCHERRER INSTITUT



## leti



WARSAW UNIVERSITY OF TECHNOLOGY



## biosensia



UTBILDNINGSVETENSKAP  
LINKÖPINGS UNIVERSITET



ik4 research alliance



UNIVERSITY of GLASGOW



EUROPEAN COMMISSION



## AREAS OF EXPERTISE:

- Nanoimprinting lithography (NIL)
- Soft lithography & Self-assembly (SLASA)
- MEMS based nanopatterning (MEMS)
- Materials
- Tools
- Modelling & Simulation



Contact us:

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**NaPa**  
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## FACTS:

- FP6 Integrated Project
- NMP Thematic Priority
- Duration 48 months (March 2004 – February 2008)
- Total volume 31 M€ (funded by EU and partners themselves)
- Contract n°: NMP4-CT-2003-500120
- Consortium composed of 35 teams from 14 countries

## TRAINING & DISSEMINATION:

- PANAMA summer schools
- NaPa focused conference sessions
- WEB site
- Newsletters
- Flyers

Designed by: 

